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Light Emitting Diodes and Planar Optical Lasers using IV  
Semiconductor Nanocrystals

Related Applications

This application claims the benefit of U.S.  
5 Provisional Application Nos. 60/441,413 filed January 22, 2003  
60/441,485 filed January 22, 2003 and 60/450,661 filed March 3  
2003.

Field of the Invention

10 The present invention relates to applications of  
group IV semiconductor nanocrystals, more specifically, light  
emitting diodes and planar optical lasers.

Background of the Invention

The dominant semiconductor material is silicon and it  
has been called the "engine" behind the information revolution.  
15 A downside of silicon is that it has poor optical activity due  
to its indirect band gap which has all but excluded it from  
the optoelectronics whose exponential growth rate surpasses  
even the vaunted "Moore's Law" of silicon integrated circuits.  
In the past two decades there have been highly motivated  
20 attempts at developing a silicon-based light source that would  
allow one to have digital information processing and optical  
communications capabilities in a single integrated silicon-  
based integrated structure. For this to be of any practical  
use, several important issues need to be addressed than just  
25 generating light. The silicon Light Emitting Diode (LED)  
source should (1) emit at a technologically important  
wavelength, (2) achieve its functionality under practical  
conditions (e.g. temperature and pump power), and (3) offer  
competitive advantage over existing technologies.

One of the materials that has gathered much international attention is erbium (Er) doped silicon (Si). The light emission from Er-doped Si occurs at the technological important 1.5 micron (1μm) wavelength. An Er doped Si emitter 5 has the minimum optical absorption of silica-based optical fibers. By exciting the first excited state of the intra-4f shell atomic transition to the ground state of the  $Er^{3+}$  ( $^4I_{13/2} - ^4I_{15/2}$ ) it emits photons at the 1.5 micron wavelength. Furthermore it has been shown that both theoretical and 10 experimental results suggest that Er in Si is Auger-excited via carriers, generated either electrically or optically, that are trapped at the Er-related defect sites and then recombine, and that this process can be very efficient due to the strong carrier-Er interactions.

15 If one tries this strong carrier-Er interaction in Er-doped bulk Si one sees a very reduced efficiency of the  $Er^{3+}$  luminescence at practical temperature and pump powers down to impractical levels. In recent papers it has been demonstrated that using silicon-rich silicone oxide (SRSO) which consists of 20 Si nanocrystals embedded in a  $SiO_2$  (glass) matrix reduces many of the problems associated with bulk Si and can have efficient room temperature  $Er^{3+}$  luminescence. The Si nanocrystals act as classical sensitizer atoms that absorb incident photons and then transfer the energy to the  $Er^{3+}$  ions, which then fluoresce 25 at the 1.5 micron wavelength with the following significant differences. First, the absorption cross section of the Si nanocrystals is larger than that of the  $Er^{3+}$  ions by more than 3 orders of magnitude. Second, as excitation occurs via Auger-type interaction between carriers in the Si nanocrystals and 30  $Er^{3+}$  ions, incident photons need not be in resonant with one of the narrow absorption bands of the  $Er^{3+}$ . However, existing approaches to developing such Si nanocrystals have only been successful at producing up to .03 percent atomic weight and this is not sufficient for practical applications, for example

erbium 100 atomic percent of  $5.81 \times 10^{22}$  atoms  $\text{cm}^{-3}$ , see Applied Physics Letter Vol 72, Num 9, 2 March 1998 pp1092-1094, J. Sin, M. Kim, S. Seo, and C. Lee.

In the past history of the semiconductor development  
5 silicon has been considered unsuitable for the optoelectronic applications. This is from the indirect nature of its energy band gap, bulk silicon is indeed a highly inefficient light emitter. There have been different approaches developed to overcome this problem, quantum confinement in silicon  
10 nanostructures and rare earth doping of crystalline silicon have received a great deal of attention. Of particular interest is silicon nanoclusters (NC) embedded in  $\text{SiO}_2$  in recent years attracted interest of the scientific community as a promising new material for the construction of visible Si-based  
15 Light Emitting Diodes (LED).

The telecommunications industry commonly uses optical fibers to transmit large amounts of data in a short time. One common light source for optical-fiber communications systems is a laser formed using erbium-doped glass. One such system uses  
20 erbium-doped glass fibers to form a laser that emits at a wavelength of about 1.536 micrometer and is pumped by an infrared source operating at a wavelength of about 0.98 micrometer. One method usable for forming waveguides in a substrate is described in U.S. Pat. No. 5,080,503 issued  
25 Jan. 14, 1992 to Najafi et al., which is hereby incorporated by reference. A phosphate glass useful in lasers is described in U.S. Pat. No. 5,334,559 issued Aug. 2, 1994 to Joseph S. Hayden, which is also hereby incorporated by reference. An integrated optic laser is described in U.S. Pat. No.  
30 5,491,708 issued Feb. 13, 1996 to Malone et al., which is also hereby incorporated by reference.

There is a need in the art for an integrated optical system, including one or more high-powered lasers along with

routing and other components that can be inexpensively mass-produced. The system should be highly reproducible, accurate, and stable.

#### Summary of the Invention

5 According to one broad aspect, the invention provides an LED comprising REDGIVN (rare earth doped group IV nanocrystal) material.

10 In some embodiments, the LED comprises in sequence: a conductive substrate and/or bottom cladding; the REDGIVN in a REDGIVN film; a conductive and transparent layer on top of the REDGIVN film; a first contact on top of the conductive and transparent layer and a second contact on the substrate; wherein the LED is turned on by applying a voltage across the first contact and the second contact.

15 In some embodiments, the substrate is selected from a group consisting of: comprises p or n silicon substrate or Transparent metal oxide semiconductors such as Zinc Oxide and III V compound semiconductor substrates, and diamond substrate; the REDGIVN layer is a silicon rich silicon oxide (SRSO) film 20 containing silicon nanocrystals doped with a rare-earth precursor; the conductive and transparent layer comprises a poly-silicon layer.

25 In some embodiments, the LED further comprises a small aperture etched through the first contact to allow emitted light out.

In some embodiments, the first contact is a serpent contact to allow emitted light out.

30 In some embodiments, the LED comprises additional rare earth dopants in the REDGIVN layer so as to produce multiple colours.

In some embodiments, the LED comprises rare earth dopants for red, green and blue so as to produce white light.

In some embodiments, the LED comprises a plurality of layers of REDGIVN each separated by a buffer layer, and each 5 containing a respective rare earth dopant.

In some embodiments, said plurality of layers of REDGIVN comprise three layers, one each for red, blue and green light.

In some embodiments, the rare earth ion are selected 10 from a group consisting of: for blue light: Tetrakis(2,2,6,6 tetramethyl-3,5-heptanedionato)cerium(IV) and Ce(TMHD)<sub>4</sub>; for a green light: Tris(2,2,6,6-tetramethyl-3,5-heptanedionato)erbium (III) Er<sup>+3</sup>(THMD)<sub>3</sub>; for a red light: Tris(2,2,6,6-tetramethyl-3,5-heptanedionato)eupropium (III) and Eu(TMHD)<sub>3</sub>.

15 In some embodiments, the conductive substrate and/or bottom cladding are also transparent so as to allow some light to exit out the bottom of the device.

In some embodiments, there is provided an array of LEDs.

20 In some embodiments, different rare earth dopants are used in respective subsets of the array.

In some embodiments, an array of LEDs is arranged in groups of three, each group of three including a red light LED, a green light LED and a blue light LED so as to produce an 25 overall white light LED.

In some embodiments, each LED is individually actuatable.

In some embodiments, each of the three LEDs has a respective different rare earth dopant so as to produce one of red, green and blue light.

5 In some embodiments, each of the three LEDs is individually actuatable.

In some embodiments, the group of LEDs is collectively actuatable.

According to one broad aspect, the invention provides an optical laser comprising REDGIVN material.

10 In some embodiments, An optical laser comprises: at least one waveguide comprising a REDGIVN channel; at least one feedback element(s) defining a laser- laser-resonator cavity in the waveguide so that laser light is output from the waveguide when pumped; a pump source.

15 In some embodiments, the pump source is a broadband optical pump source.

In some embodiments, the pump source is an electrical pump source.

20 In some embodiments, an optical laser comprises a substrate and/or bottom cladding below the waveguide and a top cladding.

In some embodiments, the laser cavity has a size, which is tuned to an excitation wavelength of the rare earth dopant.

25 In some embodiments, the at least one feedback element(s) comprise a first highly reflective mirror, and a second output coupler mirror which is partially reflective.

In some embodiments, the at least one feedback element(s) comprise a first Bragg grating which is highly

reflective, and a second Bragg grating which is which is partially reflective.

In some embodiments, the feedback elements are frequency selective, and are tuned to be most reflective near a 5 resonant frequency of the cavity.

In some embodiments, an optical laser further comprises means for varying the wavelength(s) reflected by the feedback element(s) and varying the effective length of the resonator cavity to thereby tune the laser to a selected 10 wavelength.

In some embodiments, an array of lasers is formed on a common substrate.

In some embodiments, each laser of the array of lasers has resonant characteristics and dopants selected to 15 produce a respective different wavelength.

In some embodiments, each laser has a respective laser cavity having a different length.

In some embodiments, a laser further comprises a Diffraction Bragg reflector (DBR) grating formed into or close 20 to the waveguide is used to tune the wavelength of light supported in the waveguide cavity.

In some embodiments the resonance characteristics of the waveguide cavities are individually selected by varying the pitch of the reflection gratings used to define the cavities 25 which, along with the effective refractive index for the propagated optical mode, determines the wavelengths of light reflected by the gratings.

In some embodiments, a laser comprises a surface-relief grating forming a distributed Bragg reflection grating 30 fabricated on a surface of the wave guide.

In some embodiments, a laser comprises: a conductive substrate having a first electrical contact; a transparent conductive cladding buffer; a layer comprising the wave guide, a second electrical contact on top of the REDGIVN channel; an 5 electrical pump source.

In some embodiments, the at least one feedback element(s) comprise a high reflecting mirror and output coupler at opposite ends of the waveguide to form the resonating cavity.

10 According to one broad aspect, the invention provides a laser component comprising: a thin film containing REDGIVN and having a plurality of waveguides defined by channels within the substrate; one or more feedback elements for providing optical feedback to the waveguides to form a respective laser-15 resonator cavity in each wave guide with a distinct resonance characteristic to provide lasing action at a selected wavelength when pumped, wherein injection of pump light at one or more suitable wavelengths into the laser-resonator cavity causes output of laser light at the selected wavelength in 20 accordance with a longitudinal cavity mode of the cavity.

In some embodiments, a laser further comprises: a ferrule having a plurality of spaced-apart attachment sites; and a plurality of optic fibers attached to the ferrule at a respective one of the plurality of spaced-apart attachment 25 sites, each optical fiber also being connected to receive light from a respective one of the resonator cavities.

In some embodiments, the laser-resonator cavities have a plurality of widths on a substrate surface to thereby define a plurality of effective indices of refraction for the 30 cavities, the wavelength of a longitudinal cavity mode being dependent thereon.

### Brief Description of the Drawings

Preferred embodiments of the invention will now be described with reference to the attached drawings in which:

5 Figure 1 is a schematic diagram of a first LED which uses Group IV semiconductor nanocrystals doped with rare-earth ions, provided by an embodiment of the invention;

Figure 2 is a schematic diagram of another LED provided by an embodiment of the invention, adapted to produce white light;

10 Figure 3 is a schematic of an array of LEDs provided by an embodiment of the invention;

Figure 4 is a schematic diagram of a Fabry-Perot Cavity laser provided by an embodiment of the invention;

15 Figure 5 is a schematic diagram of a distributed feedback laser provided by an embodiment of the invention;

Figure 6 is a schematic diagram of an array of DFB lasers provided by an embodiment of the invention;

Figure 7 is a schematic diagram of an array of v-grooved lasers; and

20 Figure 8 is a schematic diagram of an electrically pumped SRSO laser provided by another embodiment of the invention.

### Detailed Description of the Preferred Embodiments

Applicants provisional application <attorney docket 25 50422-1> entitled "Preparation of type IV Semiconductor Nanocrystals Doped with Rare-earth Ions and Product Thereof" filed January 22, 2003 teaches methods of preparing group IV semiconductor nanocrystals doped with rare-earth ions. In one

embodiment provided in that application, the invention provides a doped type IV semiconductor nanocrystal layer. In another aspect, the invention provides a doped type IV semiconductor nanocrystal powder comprising crystals of a group IV element 5 that bear on their surface atoms of one or more rare earth elements. The powder can also be used to form a layer, for example by including the powder in a layer of a dielectric medium for example spin on glass, or a polymer. That application is incorporated herein in its entirety by 10 reference. Two regular applications < attorney dockets 50422-7; 50422-8 > have been filed the same day as this application and are hereby incorporated by reference in their entirety. In the entire description that follows, whenever a rare-earth doped group IV nanocrystal material (REDGIVN material) is 15 referred to, any material taught in the incorporated documents is contemplated.

Figure 1 shows an example structure of an LED that is formed by a Metal Oxide Semiconductor (MOS) structure provided by an embodiment of the invention. This structure uses a p 20 silicon substrate 100 which might for example have a resistivity of 0.001. Any other suitable bottom layer could alternatively be used, for example Zinc Oxide, or Diamond. Preferably the substrate is conductive. On top of the substrate 100 there is a REDGIVN layer 102, for example in the 25 form of an Er:SRSO film. On top of the REDGIVN layer 102 is a conductive, transparent layer 108. This might for example be polysilicon, but other materials may alternatively be used. A bottom first contact 106 is shown below the substrate 100, and a second top contact 104 is shown on top of the conductive 30 transparent layer 108. Also shown is an opening 107 in the top contact layer 104 to allow light to escape.

In operation, the REDGIVN layer 102 is activated by applying a voltage across the two contacts 104,106. The

substrate 10 and the transparent conductive layer 108 serve to spread the field created between the two contacts such that substantially all of the REDGIVN layer 102 is activated. The electric field excites the nanocrystals in the REDGIVN layer 5 102 which in turn excite the rare earth dopants, which then emit at the characteristic wavelengths of the rare earth element.

There are several ways of making the device of Figure 6. The incorporated applications in particular teach a number 10 of ways of forming the REDGIVN layer 102. In an example process of making the device of Figure 6 that assumes that silicon nanocrystals are employed in the REDGIVN layer 102, the p silicon substrate 100 is cleaned and etched to remove any oxide on the silicon substrate. This cleaned and etched 15 substrate is placed into an ECR PECVD reactor and then exposed to argon plasma for 3 min after pump down to do a final clean off the silicon substrate. During the plasma clean the substrate is brought up to 300°C. silicon substrate, which might for example be n-type with a conductivity of 0.05-0.001 : cm, is 20 kept at this temperature during the Silicon Rich Silicon Oxides (SRSO) film growth. A rare-earth precursor is also turned on during the SRSO growth to dope the silicon nanocrystals. The doped SRSO film is grown, preferably from 10 nm to 1000 nm and more preferably from 100 nm - 250 nm in thickness. The 25 refractive index of this film can be measured with a ellispometer during the deposition and the silane flow adjusted to have the index of refraction be 1.85 to 1.9. This allows the SRSO film to have a Si content on the order of 42-45 at%. This is to insure high conductivity of the SRSO film and small Si 30 nanocrystals on the order of 1 nm diameter. Other values can be employed. The rare earth precursor and oxygen are turned off and a doped p<sup>+</sup> poly-silicon layer 108 of 10nm-50nm thickness and a conductivity of 0.001 for example is grown on top of the SRSO film. An element may be introduced into semiconductor

to establish either p- type (acceptors) or n- type (donors) conductivity; common dopants in silicon: p-type, boron, B; n-type phosphorous, P, arsenic, As, antimony, Sb. This is to make sure of a good transparent current sheet 5 for a top electrode. The grown structure is then placed in a RTA furnace and annealed at 950°C for 5 minutes to form the nanocrystals and optically activate the rare earth ions into it's 3+ or 2+ valance states. The result is an erbium doped SRSO film 102. After the anneal step a top contact Aluminum 10 film 104 for example of 250nm - 1000nm thick is deposited on top of the doped p<sup>+</sup> poly-silicon-Er:SRSO film 102. More generally any of the conductive metals can be employed. Aluminum has a good work function energy level so that an ohmic conductor can be made with the boron doped p<sup>+</sup> poly-silicon 15 layer. Gold would work but may need to have a chrome layer applied first or else it will peel and flake off the surface. The bottom contact 106 is also deposited on to the silicon substrate of a thickness of 500nm-2500nm thickness. An anneal of 450°C for 5 minutes is performed to form a ohmic contact on 20 the back side of the n<sup>+</sup> silicon substrate. In one embodiment, the small aperture 107 is etched through the top Aluminum contact 104 to allow emitted light 109 out. In another embodiment, a serpent top front contact can be employed to allow light exit.

25 An appropriate selection of the rare earth ion can be used to tailor the colour of the emitted light 109 from the prepared LED. For a blue light emitting diode, the rare earth metal precursor can be selected from Tetrakis(2,2,6,6-tetramethyl-3,5-heptanedionato)cerium(IV) and Ce(TMHD)<sub>4</sub>. For a 30 green light emitting diode, the rare earth metal precursor can be selected to be Tris(2,2,6,6-tetramethyl-3,5-heptanedionato)erbium (III) Er<sup>+3</sup>(THMD)<sub>3</sub>. For a red light emitting diode, the rare earth metal precursor can be selected from Tris(2,2,6,6-tetramethyl-3,5-heptanedionato)europlum (III)

and Eu(TMHD)<sub>3</sub>. This selection of rare earth metal ion precursors is not meant to be limiting.

In another embodiment, in order to extract light also from the bottom of the LED, the layer below the REDGIVN layer 5 102 is also transparent (but still conductive), and an appropriately shaped bottom contact is employed.

Figure 1 is an example of a white light LED structure based on the structure of Figure 1 but with the REDGIVN layer 102 replaced with a REDGIVN layer 110 doped with three 10 different rare earth ions, one for each of blue, red and green light to generate three different types of light which 15 collectively produce a white light emission 111. The layer 110 can be formed by simultaneously doping using different rare earth ions. In a preferred embodiment, a separate layer is used for each dopant. In some embodiments a buffer layer, for 20 example of p<sup>+</sup> poly silicon, is provided between each rare earth layer. In one example, the active region consists of a layer of REDGIVN doped with a first rare earth ion, a buffer layer of p<sup>+</sup> polysilicon, a second layer of REDGIVN doped with a second rare earth ion, a buffer layer of p polysilicon, and a third 25 layer of REDGIVN doped with a third rare earth ion, with the three layers containing respective dopants to produce red, green and blue. More generally any combination of dopants may be employed.

25 Referring now to Figure 3, shown is an array of LEDs provided by an embodiment of the invention. In the illustrated example, there are twelve LEDs 112,...,123 each based on the above described embodiment. LEDs 112,115,118,121 are blue LEDs; LEDs 113,116,119,122 are green LEDs, and LEDs 30 114,117,120,123 are red LEDs, the colour of each LED being determined by the appropriate selection of the rare earth dopant. The LEDs are also shown in four groups 124,125,126,127

of three LEDs, each group containing a respective LED of each of the three primary colours. Each such set of three LEDs can be used to form a white light LED. In one embodiment, each of the colours making up the group of three is individually 5 actuatable so as to produce a desired colour. In another embodiment, all three LEDs in a group turn on together to produce white light at a point a distance from the device where substantial combination of light has taken place. The arrangement of Figure 3 can be made using a single layered 10 process by applying the three rare earth dopants in three separate stages while masking the remaining areas. While specific examples of different colours are shown in Figure 3, it is to be understood that an arbitrary array of LEDs is contemplated.

15 Another embodiment of the invention provides a planar optical laser that is manufactured by using IV semiconductor nanocrystals that are doped with rare-earth ions such as Scandium, Yttrium and the Lanthanides. The purpose of this technology is to allow one to develop an inexpensive method of 20 manufacturing planar optical lasers for use in the telecommunication industry but is not limited to just that field. This technology is also applicable in advanced high speed back-planes and other high speed hybrid optoelectronic circuits.

25 Preferably the planar optical laser is fabricated on a flat substrate such as fused silica and/or silicon and other such suitable substrate material. The substrate could also be of a flexible nature assuming that the nanocrystal layer did not crack or peel due to the flexible nature of the substrate. 30 By using silicon wafers as the substrate one then gains access to well-established process and fabricating manufacturing facilities throughout the world. Also by developing the flexible substrate technology one would be able to exploit

roll-web processes, which would allow one to print the Planar Optical Circuits, as one would do for newspaper, magazines and other such printing technologies.

One embodiment provides optical structures and methods for producing tunable waveguide lasers. In one embodiment, a waveguide is defined within a glass substrate doped with a rare-earth element or elements by PECVD. Feedback elements such as mirrors or reflection gratings in the waveguide further define a laser-resonator cavity so that laser light is output from the waveguide when pumped optically or otherwise. The wavelengths reflected by the reflection gratings can be varied and the effective length of the resonator cavity can be varied to thereby tune the laser to a selected wavelength. For example, having a Bragg reflector as one of the feedback mirrors would allow the cavity to have a preferential high Q for the resonate of the Bragg reflector which then would re-enforce the laser frequency. The Bragg grating could be made to have a varying frequency response by having the grating tuned, for example by thermal or mechanical stress or a combination of these.

Another embodiment provides apparatus and methods for integrating rare-earth doped lasers and optics on glass substrates. The invention includes a laser component formed from a glass substrate with REDGIVN regions defining a plurality of waveguides defined by channels within the substrate. The laser component may constitute a monolithic array of individual waveguides in which the waveguides of the array form laser resonator cavities with differing resonance characteristics. The channels defining the waveguides may for example be created by exposing a surface of the substrate to which a photo resist is spin on and a mask having a plurality of line apertures corresponding to the channels, which are to be formed. Other processes may be employed.

Another embodiment provides a laser component that includes a thin film doped with one or more optically active rare earth (preferably lanthanide) species and type IV nanocrystals and having a plurality of waveguides defined by 5 channels within the film. As used herein, a "channel within the film" is meant to broadly include any channel formed on or in the substrate, whether or not covered by another structure or layer of substrate. Each substrate waveguide (or "channel") is defined within the substrate as a region of increased index 10 of refraction relative to the substrate. The semiconductor nanocrystal glass film is doped with one or more optically active rare earth species which can be optically pumped (typically a rare-earth element such as Er, Yb, Nd, or Pr and or other lanthanide elements or a combination of such elements 15 such as Er and Yb) to form a laser medium which is capable of lasing at a plurality of frequencies. Again, any of the layered structures of the incorporated embodiments may be used to form a suitable laser medium. Mirrors or distributed Bragg reflection gratings may be located along the length of a 20 waveguide for providing feedback to create a laser-resonator cavity. One or more of the mirrors or reflection gratings is preferably made partially reflective for providing laser output.

An example of a waveguide laser based Fabry-Perot 25 Cavity laser is shown in Figure 4. This example shows a substrate 130 which may for example be silica, but could be any other appropriate substrate material. On top of this is a cladding layer 132, a core wave guiding layer 134, and a top cladding layer 136. The wave guiding layer 134 also contains 30 REDGIVN. Also shown is an HR (high reflectivity) mirror 138 and an OC (output coupler) mirror 140. The arrangement of Figure 4, when pumped, spontaneously emits a light which resonates and eventually exits as output light source 142 through the OC mirror 140 which is partially reflective to

allow some light to escape. The laser of Figure 4 is preferably optically pumped.

In the arrangement of Figure 4, the feedback components employed are in the form of the pair of mirrors 5 138,140. This produces a Fabry-Perot Cavity. The laser component may constitute a monolithic array of individual waveguides in which the waveguides of the array form laser resonator cavities with differing resonance characteristics (e.g., resonating at differing wavelengths). The component may 10 thus be used as part of a laser system outputting laser light at a plurality of selected wavelengths.

The frequency response of the arrangement of Figure 9 is generally indicated at 143 where it has been assumed that Erbium was used as the rare earth dopant. The size of the 15 cavity (distance between HR mirror 138 and OC mirror 140) is tuned to resonate near the active frequencies for Er. This results in the lasing to occur at the active frequencies for Er which include a dominant frequency and several other nearby frequencies which are emitted with less power as shown. In 20 general, the cavity size is preferably substantially matched to the peak in the fluorescence response for the particular rare earth dopant to achieve peak efficiency.

In certain embodiments of the invention, the resonance characteristics of a waveguide cavity are varied by 25 adjusting the width of the channel formed in the film, which thereby changes the effective refractive index of the waveguide. The effective refractive index can also be changed by modifying the diffusion conditions under which the waveguides are formed as described below. A diffraction Bragg 30 reflector (DBR) grating formed into or close to the waveguide is used, in some embodiments, to tune the wavelength of light supported in the waveguide cavity. Changing the effective refractive index thus changes the effective wavelength of light

in the waveguide cavity, which determines the wavelengths of the longitudinal modes supported by the cavity. In another embodiment, the resonance characteristics of the waveguide cavities are individually selected by varying the pitch of the 5 DBR reflection gratings used to define the cavities that, along with the effective refractive index for the propagated optical mode, determines the wavelengths of light reflected by the gratings. In still other embodiments, the location of the gratings on the waveguide is varied in order to select a laser-10 resonator cavity length that supports the desired wavelength of light.

In one embodiment, a surface-relief grating forming a distributed Bragg reflection grating is fabricated on the surface of the waveguide, for example by coating the surface 15 with photo resist, defining the grating pattern in the photo resist holographically or through a phase mask, developing the photo resist pattern, and etching the grating pattern into the waveguide with a reactive ion system such as an argon ion mill. In certain embodiments, a more durable etch mask allowing more 20 precise etching and higher bias voltages is obtained by depositing chromium on the developed photo resist pattern using an evaporation method which causes the chromium to deposit on the tops of the grating lines. This forms a much more durable mask for the reactive ion system allowing a deeper etch which 25 would be required for a thicker active volume.

An example of a distributed feedback laser based on the above embodiment is shown in Figure 10. This embodiment shows a substrate 152, bottom cladding 160, core 162 and top cladding 164. The reflecting components consist of an HR 30 mirror 150 and an OC mirror 154. In this embodiment, the core is in the form of a distributed bragg reflection grating which might for example have been formed as described above. The shape used to show the core is illustrative of the Bragg

grating characteristic that concerns an oscillating index of refraction, and is not necessarily indicative of the physical shape of the core. The core also contains rare-earth doped nanocrystals. The OC mirror 154 in this example is slightly 5 less reflective than the HR mirror resulting in light 166 exiting the arrangement and forming the output of the laser. In this embodiment, the cavity again defines the wavelength of the laser and this needs to be substantially set near the active wavelengths of the rare earth dopants. Preferably, the 10 grating 162 is also tuned to one of these wavelengths. This causes the arrangement to lase substantially at the single frequency for which the arrangement is tuned. Thus, the frequency response of this arrangement, shown generally at 155 has a single peak.

15 A first example of an array of lasers will now be described with reference to Figure 6. In this example, there are four lasers generally indicated by 210, 212, 214, 216. Each laser 210, 212, 214, 216 has a respective first Bragg grating 170, 172, 174, 176 (although other reflective elements may 20 alternatively be employed) a respective core area 178, 180, 182, 184 forming a laser cavity and a respective second Bragg grating 188, 190, 192, 194 (although other output reflective elements can be employed. In the illustrated example, one set of gratings 170, 172, 174, 176 is almost completely reflective for 25 example having 99% reflectivity. The other set of gratings 1788, 180, 182, 184 is slightly less reflective to allow some light through as an output signal. In the illustrated example, the second set has 96% reflectivity.

30 The lasers have outputs 200, 202, 204, 206 which generate wavelengths O<sub>4</sub>, O<sub>3</sub>, O<sub>2</sub>, O<sub>1</sub> respectively. It is of course to be understood that any number of lasers can be included in an array such as the array of Figure 6. Four are shown simply by way of example. Here, the characteristics of

each laser in the array are tuned to generate the respective wavelength. This can be done by adjusting the first and second bragg gratings of a given laser and/or by adjusting the length of the cavity. As in previous embodiments, the core region of 5 each laser is constructed using SRSO doped with rare-earth ions. The array of lasers of Figure 6 can be formed in a single layered structure with the four lasers being side by side in a respective channel within the substrate for example. The frequency response of the arrangement of Figure 6 is 10 generally indicated at 201, and shows a respective frequency for each laser. In this case, by tuning the bragg gratings a narrow frequency response can be generated for each laser output.

An individual laser can also be formed using the 15 embodiment of Figure 6. Furthermore, in another embodiment, the arrangement of Figure 6 is provided, but oriented orthogonally to the arrangement shown. This consists of a substrate, a first layer containing a Bragg grating, a second layer containing the core/cavity, and a third layer containing 20 a second partially reflective Bragg grating. This arrangement produces a laser that emits light out the top of the device.

Figure 7 is another example of an array of lasers provided by an embodiment of the invention. Again, the array is shown to include four separate lasers 350,352,354,356, but 25 any appropriate number of lasers could alternatively be provided. In this embodiment, each laser has an HR mirror 300,302,304,306, and an active SRSO segment 310,312,314,316. The active SRSO segment of each laser is followed by an output coupler 360,362,364,368. The arrangement thus far is 30 substantially similar to the arrangement of Figure 6, which was a perspective view whereas the view of Figure 7 is a top view. The output couplers 360,362,364,368 couple the output of the active SRSO segments 310,312,314,316 into a v groove section

320, 322, 324, 326 that in turn is coupled to output fibers 330, 332, 334, 336 connected to output couplers 340, 342, 344, 346.

In a variant of the above described embodiment, the output fibers can be attached to a single a ferrule having a 5 plurality of spaced-apart attachment sites.

The embodiments above have assumed optical pumping. More generally several examples of methods of pumping REDGIVN are provided in applicant's co-pending application no. <attorney docket no. 50422-5> filed on the same day as this 10 application which is based on U.S. provisional application no. 60/441485 hereby, both of which are hereby incorporated by reference in their entirety. Those applications involve pumping for the purpose of amplification. However, the same principles are applicable here for pumping in the context of 15 lasers. Optical pumping and electrical pumping are disclosed and contemplated for these laser applications.

When electrical pumping is used instead of optical pumping the substrate is conductive, for example an n<sup>+</sup> silicon substrate, to which a transparent conductive cladding buffer 20 such as zinc oxide (ZnO) film, for example of from 2000 to 6000 nm, is applied. A REDGIVN film, for example having a thickness of from 100 to 500nm, is deposited on transparent conductive layer and annealed. A top electrical contact, for example 500- 25 1000nm of Indium Tin Oxide (ITO), is deposited on top of the REDGIVN film. Alternatively, a p<sup>+</sup> poly-silicon layer can also be used as well as a cadmium oxide CdO film and other metal oxides. One would make the choice based on whether the REDGIVN film is a positive (hole) donor or negative (electron) donor. This is then masked and etched to form a active waveguide in 30 which HR mirror and output coupler placed at each end of the waveguide to form the resonating cavity.

Figure 8 shows an example featuring electrical pumping. Shown is an n+ silicon substrate 400 having a bottom electrical contact 402. Shown is a ZnO film 406 on top of the n+ silicon substrate 400. On top of the ZnO film there is a 5 layer of rare-earth doped SRSO film 408 to which is applied a top contact layer 404 which might for example be Indium Tin Oxide as in the above example. As in some previous embodiments, shown is an HR mirror 410 and an output coupler 412 through which an output light signal 414 passes. More 10 generally, the electrical pumping can be used for any of the embodiments described herein with appropriate modifications.

Numerous modifications and variations of the present invention are possible in light of the above teachings. It is therefore to be understood that within the scope of the 15 appended claims, the invention may be practised otherwise than as specifically described herein.

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